**ORIGINAL PAPER**



# **Visible light‑induced cationic photopolymerization by diphenyliodonium hexafuorophosphate and benzothiadiazole dyes**

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# **Abstract**

New benzothiadiazole-based long-wavelength organic dyes (**Y-1** and **Y-2**) were prepared for efectively sensitizing diphenyliodonium hexafuorophosphate (IOPF) to initiate the fast curing of bisphenol-A epoxy resin (E51) under visible light, avoiding traditional UV light sources that have high energy and high radiation. **Y-1** and **Y-2** have absorption spectra extended to more than 550 nm. By using **Y-1** and **Y-2** as photosensitizers for IOPF, E51 reach high epoxy conversions of 95% under light wavelength of 470-nm irradiation. IOPF and benzothiadiazole dyes present at the same time show good visible-light initiating activity. The high curing conversions are attributed to the photoelectron transfer reaction between diphenyliodonium hexafuorophosphate and benzothiadiazole dyes, based on our photochemical and electrochemical experiments. In addition, the terminated groups or of **Y-1** (–F) and **Y-2**  $(-OCH<sub>3</sub>)$  have a great influence on the photopolymerization rate of the curing systems and thermal properties of E51 after cured. In addition, E51 was even polymerized about 70% in the presence of 510-nm light flter.

**Keywords** Visible-light curing · Benzothiadiazole · Diphenyliodonium hexafuorophosphate · Long-wavelength organic dyes · Bisphenol-A epoxy resin

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## **Introduction**

Nowadays, light curing technologies have been widely used on coating industry, food packing and material forming and processing, e.g., 3D printing [\[1–](#page-11-0)[5\]](#page-11-1). The light curing induced by visible light and even infrared light is more harmless to the human body than that induced by ultraviolet (UV) lights [\[6](#page-11-2)]. A variety of photoinitiators, dyes and other photosensitizers as well as modifed monomers or prepolymers have been successfully developed to match diferent light wavelengths [[7](#page-11-3)[–9\]](#page-11-4).

Diphenyliodonium hexafuorophosphate (IOPF) is a conventional cationic UV photoinitiator [[10](#page-11-5), [11](#page-11-6)]. A broader spectrum can be matched by adding dye sensitizers to improve the visible-light initiation activity of IOPF, and thus, the epoxides can be initiated to crosslink under visible light  $[12–14]$  $[12–14]$  $[12–14]$ . Epoxy resin is a common epoxides in the curing system [[15](#page-11-9)[–17](#page-11-10)]. Many industrial applications use epoxy resin as one of the engineering polymer materials, such as coating and adhesive substances, semiconductor manufacturing [[18,](#page-12-0) [19](#page-12-1)]. The bisphenol-A type of epoxy resin (E51) is inexpensive aromatic epoxy resin. It was often used as thermal curing materials and has slow photopolymerization rate [\[20,](#page-12-2) [21](#page-12-3)]. Researches have been focused on promoting E51 to fast cationic photopolymerization instead of thermal curing in the past few years, due to its good properties after polymerized [\[22–](#page-12-4)[26](#page-12-5)].

Wang et al. [[22](#page-12-4)] studied the photoinitiated and thermally initiated cationic polymerizations of diglycidyl ether of bisphenol A epoxy oligomer. Abadie et al. [\[23\]](#page-12-6) concluded suitable addition of the sulfonium salt lowered the activation energy for the bisphenol-A epoxy system. Vabrik et al. [[24\]](#page-12-7) successfully synthesized diglycidyl ether of bisphenol-A epoxy resin-acrylated polyurethane semiinterpenetrating polymer networks upon irradiation with ultraviolet light. Chen et al. [[25](#page-12-8)] developed a two-component photoinitiator system for promoting cationic polymerization of bisphenol-A-based epoxy under visible light. Wang et al. [\[26\]](#page-12-5) synthesized dyes to sensitize iodonium bis(4-methylphenyl)hexafuorophosphate for cationic polymerization of E51 under the laser diode at 455 nm. These results indicate that using this safe and low-cost bisphenol-A epoxy resin and its derivatives is practical in the feld of light curing technology.

Dyes with diferent structures and absorption ranges have been reported as long-wavelength sensitizers in the visible-curing systems initiated by diphenyliodonium hexafuorophosphate [\[9,](#page-11-4) [27](#page-12-9)]. However, benzothiadiazole-based organic dyes are few involved. Among the dyes, benzothiadiazole is a good electronattracting group that forms a push–pull structure with an electron-donating group. A long-conjugated molecule forms from the structure, which broadens the longwavelength absorption spectrum. In the feld of dye-sensitized solar cells, it is reported that benzothiadiazole-based dyes can match the simulated solar light [\[28–](#page-12-10)[31](#page-12-11)]. In addition, 4,7-dibromo-2,1,3-benzothiadiazole is very reactive for nucleophilic substitution reactions and coupling reactions [\[32\]](#page-12-12). Benzothiadiazole functionalized dyes are readily accessible. The side groups on benzothiadiazolebased molecules afect the HOMO level. Inserting fuorine lowers the HOMO,

but introducing alkoxy raises it [\[33\]](#page-12-13). Using long-wavelength benzothiadiazole functionalized molecules to interact with UV photoinitiator are promising for application in sensitization of curing systems upon visible light. Their fexible molecular orbital energy levels have a positive infuence on matching with iodonium salt to generate synergistic efect.

In this study, a series of visible-light curing systems based on two benzothiadiazole dyes with diferent ratios of IOPF were designed. Facile synthesis of the two benzothiadiazole dyes was accomplished in our laboratory. Near-infrared (NIR) and UV–visible spectroscopy technologies were utilized for detecting epoxy conversion of E51 and photolysis of photoinitiator, dye and their mixtures, respectively. In the light curing study, cationic photopolymerization of E51 were investigated under a 470-nm light emitting diode (LED) irradiator in the absence and presence of 510 nm light flter. The infuence of dye absorption, the photoelectron transfer reaction between IOPF and dyes and sample thickness on the curing systems of E51 were studied, and discussion for further understanding the structure–property relationship were also involved. There are still few 510-nm photosensitizers for photopolymerization. The two benzothiadiazole dyes have good interact with IOPF under both 470-nm light and 510-nm light, and it is hoped to be a very promising candidate for long-wavelength light curing technology.

# **Experimental**

### **Materials**

The materials and agents used were as follows: diphenyliodonium hexafuorophosphate (IOM, cationic photoinitiator, TCI (Shanghai) Chemical Industry Development Co., Ltd.); benzothiadiazole dyes (**Y-1** and **Y-2**) were prepared in our laboratory; bisphenol-A epoxy resin (E51, photosensitive resin, Jiangsu Sanmu Group Co. Ltd.); epichlorohydrin  $(C_3H_5ClO,$  chemical pure, Beijing Chemical Works). The initial material 4,7-dibromo-2,1,3-benzothidiazole is purchased from Energy Chemical (Beijing). Tetrabutylammoniun hexafluorophosphate (n-Bu<sub>4</sub>NPF<sub>6</sub>) of 0.1 M was added into a dichloromethane solution (DCM) as electrolyte, which was purchased from Tokyo Chemical Industry Co., Ltd. (Tianjin), for cyclic voltammetry (CV) measurements.

#### **Synthesis of benzothiadiazole dyes**

The synthetic route of **Y-1** and **Y-2** is shown in Scheme [1](#page-3-0). The intermediates 1 and 2 are prepared according to literatures [\[34](#page-12-14)[–37](#page-12-15)].

Synthesis of **1** and **Y-1**: 10-mmol p-fuorobromobenzene, 20-mmol KOH and 20-mL DMSO solution were sequentially added into a one-neck round fask of 100 mL to form a mixture, which was stirred 10 min at room temperature. Then, 10 mmol of p-fuoroaniline was added to the system. Their reactions lasted 2 h at room temperature in the dark. Finally, products were obtained by extracting three



<span id="page-3-0"></span>**Scheme 1** The synthesis route of **Y-1** and **Y-2**

times with a water/ethyl acetate mixture of 40/20 mL, and the organic solvent was removed without purifcation. Then, 1.0 mmol 4,7-dibromo-2,1,3-benzothidiazole, 3.0 mmol compound 2, 0.9-g  $Pd_2(dba)$ <sub>3</sub>, 448-mg t-BuOK, 0.14-mL  $P(t-Bu)$ <sub>3</sub> and 30-mL toluene reacted 12 h in a 100-mL two-neck fask under argon. After the reaction product was extracted with ethyl acetate, the extracts passed through a column  $(PE: EA = 20:1).$ 

**Y-1**: This was <sup>1</sup>H NMR (400 MHz, DMSO-d<sub>6</sub>) δ 7.15–7.10 (m, 10H), 7.03 (m, 8H). 13C NMR (101 MHz, CDCl3) δ 162.09, 159.68, 154.07, 145.92, 145.89, 137.65, 131.82, 127.18, 127.10, 125.88, 118.01, 117.79.

Synthesis of **2** and **Y-2**: The synthetic procedure of **2** and **Y-2** is the same as Synthesis of **1** and **Y-1**, 10-mmol p-methoxybromobenzene was used instead of 10-mmol p-fuorobromobenzene.

**Y-2**: this was <sup>1</sup>H NMR (400 MHz, DMSO-d<sub>6</sub>) δδ 7.08–7.03 (m, 10H), 6.91-6.87 (m, 8H), 3.73 (s, 6H).13C NMR (101 MHz, CDCl3) δ 158.21, 154.09, 146.49, 142.89, 137.66, 128.04, 126.03, 125.95, 125.47, 117.74, 117.52, 116.61, 57.43.

#### **UV–Vis absorption, fuorescence emission spectroscopic and CV measurements**

IOPF, dyes and E51 were weighed and fully mixed, and samples include IOM/**Y-I**/E51, IOM/**Y-2**/E51, IOM/E51, **Y-1**/E51 and **Y-1**/E51.UV–vis absorption spectra were measured by UV-2600 UV–vis spectrophotometer (Shimadzu, Japan). Absorption changes with irradiation time were measured for dichloromethane solution of IOPF, dyes and IOPF/dye/E51 under a light source (FUV-6BK UV curing machine connecting with light emitting diode (LED) irradiator (470 nm), Guangzhou Banwoo Electronic Technology Co., Ltd.). The fuorescence emission spectra of **Y-1** and

**Y-2** are also compared. The fuorescence spectra conducted on a F-4500 fuorescence spectrophotometer (Hitachi, Japan) were used.

The CV tests were performed on a Zennium electrochemical workstation (ZAH-NER, Germany) using a three-electrode system. Oxidation and reduction potentials of **Y-1** and **Y-2** were determined by cyclic voltammetry (CV) in acetonitrile solutions containing 0.1 M NBu<sub>4</sub>PF<sub>6</sub> as a supporting electrolyte.

#### **NIR spectroscopy measurement**

NIR spectroscopy was performed on a 5700 infrared spectrometer (Nicolet, USA) to analyze the curing samples to detect the characteristic absorption peaks changes for the epoxy group of E51 with illumination time. The sample prepared was placed in a plastic round-hole mold with a diameter of 6 mm. An average value was determined from three repeated NIR tests. The light source for cationic light curing was an LED irradiator with a wavelength of 470 nm (110 mW cm−2, A single-channel UV-A illuminometer, Beijing Normal University Optoelectronic Instrument Factory). When a flter was used, it was placed between the LED irradiator and the sample. The epoxy conversions were calculated by detecting the characteristic absorption peak of epoxy groups (at  $6071 \text{ cm}^{-1}$ ) with illumination time [\[25](#page-12-8), [26](#page-12-5)]. The equation is as below.

$$
E\text{poxy conversion }\% = \left[1 - \left(\frac{S_T}{R_T}\right) / \left(\frac{S_0}{R_0}\right)\right] \times 100\%
$$

where  $S_T$  is the area of the epoxy C–H characteristic absorbance peak,  $S_0$  is the initial area of the epoxy C–H characteristic absorbance peak,  $R<sub>T</sub>$  is the area of the reference peak (at 4678 cm<sup>-1</sup>) and  $R_0$  is the initial area of the reference peak.

#### **Thermal stability test**

Thermal stability study for the products of IOPF/**Y-1**/E51 and IOPF/**Y-2**/E51 after cured was investigated by thermogravimetry (TG) analyses. TG curves were performed on TG 209 F3 Tarsus (NETZSCH, Germany) at a heating rate of 10 °C/min under a nitrogen atmosphere.

## **Results and discussion**

# <span id="page-4-0"></span>**Absorption, fuorescence emission spectra and cyclic voltammograms of Y‑1 and Y‑2**

The synthetic **Y-1** and **Y-2** was characterized by <sup>1</sup>H NMR and <sup>13</sup>C NMR spectra, as shown in Supplementary Materials. As shown in Fig. [1](#page-5-0)a, b, **Y-1** has a stronger absorption band than **Y-2**, while much weaker fuorescence emission than that of **Y-2** when at the same concentration. UV–vis absorption spectrum of IOPF of 10−4 M in dichloromethane is shown in Fig. [1](#page-5-0)c. The absorption of IOPF is limited at UV region. It is necessary for IOPF to induce visible light curing by incorporating with long-wavelength dyes. In our studied dyes, the  $-F$  and  $-OCH<sub>3</sub>$ -terminated



<span id="page-5-0"></span>**Fig. 1** UV-Vis absorption (**a**) and fuorescence emission spectra (**b**) of **Y-1** and **Y-2** in dichloromethane with concentrations of 10−4 M. **c** UV–vis absorption spectra of IOPF of 10−4 M in dichloromethane. **d** Cyclic voltammograms of **Y-1** and **Y-2** in dichloromethane

substitutes have an impact on their spectral properties. The visible-light absorption of **Y-1** and **Y-2** is exhibited by the distinct peak at 524 and 506 nm, respectively. The infuence of dye structure on their electrochemical behavior was evaluated by



<span id="page-5-1"></span>**Fig. 2** Normalized absorption, fuorescence emission spectra of **Y-1** and **Y-2** in dichloromethane

CV method, as shown in Fig. [1d](#page-5-0). The frst oxidation potentials of **Y-1** and **Y-2** are 0.874 V and 0.899 V. Figure [2](#page-5-1) displays the normalized absorption and fuorescence emission spectra of **Y-1** and **Y-2** in dichloromethane. The smaller band gap of **Y-1** than **Y-2** suggests that a stronger conjugation was obtained by introducing two methoxy groups. This is consistent with its redshift maximum absorption peak. For their energy levels, the optical band gap  $(E_g^{\text{opt}})$  of **Y-1** and **Y-2** are calculated to be 3.45 and 3.76 eV by measuring the intersection wavelength of absorption and fuorescence spectra in Fig. [2](#page-5-1) [[38\]](#page-12-16). The above-spectroscopic and electrochemical data of **Y-1** and **Y-2** are listed in Table [1.](#page-6-0) Based on the Rehm–Weller equation, the free energy changes ( $\Delta G_{el}$ ) for the photoelectron transfer reaction between the excited states of **Y-1**/**Y-2** and IOPF were separately calculated. The reduction potential of IOPF is −0.653 V [\[39](#page-12-17)]. The calculated values of  $\Delta G_{\text{el}}$  are negative for IOPF/**Y-1** and IOPF/**Y-2**. Therefore, the photoelectron transfer between IOPF and the studied dyes is thermodynamically allowed.

## **Theoretical calculations and thermal properties**

To gain insight into the electronic properties and geometries of **Y-1** and **Y-2**, quantum chemical calculations based on DFT at the B3LYP/6-31G level were carried out. The optimized geometric structures and frontier orbital of **Y-1** and **Y-2** are shown in Fig. [3](#page-7-0). From Fig. [3](#page-7-0)a, the dihedral angles between the benzothiadiazole core and the diphenylamine of **Y-1** are (C20–C12–N10–C3, 39.609°) and (C35–C14–N11–C6, 42.953°), and those of **Y-2** are (C20–C12–N10–C3, 40.115°) and (C35–C14–N11–C6, 40.115°). The bond lengths between the benzothiadiazole core and the diphenylamine of **Y-1** are (1.414 Å, N10–C3) and (1.415 Å, N11–C6), and those of **Y-2** are (1.416 Å, N10–C3) and (1.416 Å, N11–C6). The result is attributed to **Y-2** incorporating bis(4-fuorophenyl)amine having a very symmetric confguration as compared to **Y-1** with 4-fuoro-*N*-(4-methoxyphenyl)aniline. Both Y-1 and Y-2 have a capability of photoinduced electron transfer by the HOMO–LUMO excitation, according to and frontier orbital results from Fig. [3b](#page-7-0). The highest occupied molecular orbital (HOMO) of **Y-1** and **Y-2** almost delocalize over the whole molecule, while the lowest unoccupied molecular orbital (LUMO) is localized at the benzothiadiazole core.

## **Photopolymerization**

NIR technology was utilized to study the variation in epoxy conversion with illumination time for the visible-curing systems: IOPF/**Y-1**/E51 and IOPF/**Y-2**/E51. The

Name	$\lambda_{\rm max}^{\rm abs}\!/\!{\rm nm}$		$\lambda_{\text{max}}^{\text{fl}}/ \text{nm}$	$E_{\alpha}$ /V		$E_{\text{red}}/V$	$E_{\rm g}^{\rm opt}$ /eV	$\Delta G_{\rm el}$ /eV
Y-1	293	525	426	0.874	0.529	0.767	3.45	$-1.93$
$Y-2$	281	506	360	0.899	0.527	0.837	3.76	$-2.21$

<span id="page-6-0"></span>**Table 1** Photochemical and electrochemical data of Y-1 and Y-2



$$
Y-1
$$







<span id="page-7-0"></span>**Fig. 3** Optimized geometric structures (**a**) and frontier orbitals (**b**) of **Y-1** and **Y-2**

efects of IOPF/benzothiadiazole-based organic dyes ratio, sample thickness and diferent light irradiation on the curing systems of cationic polymerization of E51 were investigated. The curing systems of IOPF/E51, **Y-1**/E51 and **Y-2**/E51 are also analyzed for comparison. A LED light irradiator with the wavelength of 470 nm was applied for our research. A flter of 510 nm with transmittance about 86% were subsequently used, and the measured transmittance value is shown in Supplementary Materials (Fig. S1).

Figure [4](#page-8-0)a shows the epoxy conversion of E51 as a function of irradiation time under 470-nm LED irradiator. The amount of IOPF and two organic dyes are 2.0 wt.% and 1.0 wt.%, separately. At 470-nm light with intensity of 110 mW  $cm^{-2}$ and sample thickness of 120 μm, E51 conversions reach up to 94.3% and 94.9% by IOPF sensitized by **Y-1** and **Y-2**. IOPF/Y-2/E51 exhibits a faster curing rate than IOPF/**Y-1**/E51. This result may be related to the photoelectron transfer between IOPF and the studied dyes. As calculated in section ["Absorption, fuorescence emis](#page-4-0)[sion spectra and cyclic voltammograms of](#page-4-0) **Y-1** and **Y-2**," the calculated free energy changes ( $\Delta G_{el}$ ) for the photoelectron transfer reaction between the excited states of **Y-2** and IOPF  $(-2.1 \text{ eV})$  is more negative than that between the excited states of **Y-1** and IOPF (−1.93 eV), suggesting higher reactivity for IOPF and **Y-2** [[25\]](#page-12-8). In addition, the curing results of polymerizations in the IOPF/E51, **Y-1**/E51 and **Y-2**/



<span id="page-8-0"></span>**Fig. 4 a** Epoxy conversions of E51 under 470-nm LED irradiator with increasing irradiation time; **b** Epoxy conversions of E51 initiated by IOPF/Y-1, IOPF **c** IOPF/Y-2 in the presence of 510-nm flter; and **d** TG analyses of IOPF/Y-1/E51 and IOPF/Y-2/E51 in the presence of 510-nm flter. The percentages of IOPF, Y-1 and Y-2 are mass fraction

E51 system show that IOPF initiated E51 alone achieves conversion about 6.2%, and also the **Y-1**/E51 and **Y-2**/E51 systems cannot induce E51 alone under LED light.

In order to further understand the structure–conversion relationship of the studied curing systems, a 510-nm flter was put between the LED irradiator and the sample. Diferent ratios of IOPF/benzothiadiazole dyes and sample thickness were investigated for the curing systems. The curing results of IOPF/**Y-1**/E51 and IOPF/**Y-2**/ E51 systems are shown in Fig. [4](#page-8-0)b, c. In the presence of 510-nm flter, both the IOPF/**Y-1**/E51 and IOPF/**Y-2**/E51 system approach epoxy conversions close to 70%. In Fig. [4b](#page-8-0), the concentration of IOPF and **Y-1** has greatly infuenced the epoxy conversion in IOPF/**Y-1**/E51 systems. Although the concentration ratio of IOPF/**Y-1** are the same as 2:1, the IOPF of 4 wt.% with sensitization by **Y-1** of 2 wt.% exhibits much faster initiation performance than IOPF of 2 wt.% with **Y-1** of 1 wt.%. The increase in concentrations of photoinitiator and photosensitizer greatly enhanced the curing performance of E51 under flter. Meanwhile, IOPF/**Y-1** initiated E51 more efficiently at 60-μm sample thickness than that at  $120$ -μm sample thickness. The photoinitiation rate of IOPF/**Y-1** is apparently infuenced by changing sample thickness. In contrast, the IOPF of 4 wt.% with sensation by **Y-2** of 2 wt.% exhibits good initiation performances at both 60-μm and 120-μm sample thicknesses, as shown in Fig. [4](#page-8-0)c. The photoinitiation rate of IOPF with **Y-2** at 60-μm sample thickness is only a little faster than at 120-μm simple thickness. On the whole, curing systems based on **Y-2** have better activity than those based on **Y-1** under the long-wavelength light of 470 nm and 510 nm. As known, IOPF have no absorption at 470 nm and 510 nm. **Y-1** has wider absorption band range, but maybe a stronger synergistic interaction occurs between IOPF and **Y-2** than that between IOPF and **Y-1**.

Besides, the products after cured under 510-nm flter of IOPF/**Y-1**/E51 and IOPF/**Y-2**/E51 show good properties on thermal stability. Based on TG analyses in Fig. [4d](#page-8-0), IOPF/Y-1/E51 and IOPF/Y-2/E51 display a thermal decomposition temperature  $(T_d)$  of 364.2 °C and 327.2 °C, and the weight losses during TG are 15% and 4% upon heating up to 300 °C, respectively. Y-1 and y-2 sensitized IOPF not only accelerated the curing of E51, but also obtained the curing polymer with high thermal stability [\[25](#page-12-8)]. IOPF/benzothiadiazole dyes are very promising candidate photoinitiation system for visible light curing beyond 500 nm. This work is hoped to provide experimental basis for such long-wavelength irradiated curing applications.

#### **Synergistic efect of IOPF and benzothiadiazole dyes**

UV–vis absorption spectra were employed to compare the absorption peak changes of IOPF/benzothiadiazole dyes mixtures and benzothiadiazole dyes alone before and after illumination. The interaction between IOPF and benzothiadiazole dyes was further studied. Figure [5](#page-10-0) presents normalized absorption changes with illumination time of IOPF/**Y-1**, IOPF/**Y-2**, **Y-1** and **Y-2** in solution, respectively. The absorbance was measured at a certain interval.

Figure [5a](#page-10-0) shows a new absorption at 600–800 nm increases at frst and then gradually decreases for IOPF/**Y-1**, so as that shown in Fig. [5b](#page-10-0) for IOPF/**Y-2**. The decreasing change of absorption at around 510 nm favors the synergistic efect of



<span id="page-10-0"></span>**Fig. 5** Photolysis of **a** IOPF/**Y-1**, **b** IOPF/**Y-2**, **c Y-1** and **d Y-2** in epichlorohydrin

**Y-1** and **Y-2** on sensitizing IOPF even in the presence of the flter. The results indicate consumption of dyes occurs under interactions with IOPF. As a comparison, Fig. [5](#page-10-0)c, d displays the main absorption of Y-1 and Y-2 does not change with prolonged illumination, and there is almost no photolysis in the solution of benzothiadiazole dyes alone. Thus, the synergistic efect of benzothiadiazole dyes with IOPF can be inferred from the phenomena, and it enhances the efficient initiation of E51 to be fast cured under visible light [\[40](#page-13-0)].

## **Conclusions**

The synthesized benzothiadiazole dyes (**Y-1** and **Y-2**) assist the UV photoinitiator IOPF in the absorption of visible light, and they can efectively initiate the curing of bisphenol-A epoxy resin (E51) under 470-nm LED irradiator in the absence and presence of 510-nm flter. The parameters of IOPF/**Y-1**/E51 and IOPF/**Y-2**/E51 curing are investigated using NIR spectroscopy and photolysis. **Y-1** has superiority of longer maximum absorption wavelength at 525 nm than that of **Y-2** at 506 nm. However, IOPF/**Y-2** initiated E51 much faster than IOPF/**Y-1**, which is possibly due to easier synergistic efect between IOPF and **Y-2**. The fnal epoxy conversions of IOM/**Y-1**/E51 and IOM/**Y-2**/E51 curing systems are close to 95% under the 470-nm LED irradiator and even reach 70% in the presence of 510-nm flter. The photolysis

of IOPF and benzothiadiazole dyes has good activity after mixing, from which a synergistic effect between the two is inferred.

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